TSMC-00-166





December 14, 2000

To: Commissioner of Patents and Trademarks

Washington, D.C. 20231

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Subject:

Serial No. 09/679,514 10/06/00

Hung-Jen Hsu, Yu-Kung Hsiao, Chih-Kung Chang, Sheng-Liang Pan, Kuo-Liang Lu

A METHOD TO IMPROVE PASSIVATION FOR OPENINGS BY REFLOW OF PHOTORESEST TO ELIMINATE TAPE RESIDUE

Grp. Art Unit:

INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation In An Application.

The following Patents and/or Publications are submitted to comply with the duty of disclosure under CFR 1.97-1.99 and 37 CFR 1.56. Copies of each document is included herewith.

U.S. Patent 5,063,655 to Lamey et al., "Method to Integrate Drive/Control Devices and Ink Jet on Demand Devices in a Single Printhead Chip", teaches a method to integrate the driver pulse circuitry and the resistors of an ink jet printer onto the printer head.

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- U.S. Patent 5,731,243 to Peng et al., "Method of Cleaning Residue on a Semiconductor Wafer Bonding Pad", teaches a method to reduce protective tape adhesive contamination.
- U.S. Patent 6,060,378 to Rolfson, "Semiconductor Bonding Pad for Better Reliability", discloses a method to form bonding pads with improved reliability.
- U.S. Patent 6,025,275 to Efland et al., "Method of Forming Improved Thick Plated Copper Interconnect and Associated Auxiliary Metal Interconnect", discloses a method to form thick plated copper interconnects.

Sincerely

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